



CITY OF KIRKLAND

Planning and Building Department

123 Fifth Avenue, Kirkland, WA 98033 - (425) 587-3225

www.kirklandwa.gov

CITY OF KIRKLAND NOTICE OF DECISION

September 28, 2015

Permit application: MS 3 Short Plat ([SUB15-01532](#))

Location: [12805 NE 112th Street](#)

Applicant: Dan O'Neill, Meridian, Inc.

Project description: Subdivide a 13,919 square foot parcel into 2 single family lots in the RSX 7.2 Zone. The applicant is proposing to retain the existing house on proposed Lot 1. An integrated development plan is not included with the short plat (see Attachments 1 and 2).

Decisions Included: Short Plat (Process I)

Project Planner: Ron Hanson, Planning Consultant

SEPA Determination: Exempt

Department Decision: **Approval with Conditions**


Eric Shields, Director
Planning and Building Department

Decision Date:	September 23, 2015
Appeal Deadline:	October 12, 2015

Affected property owners may request a change in valuation for property tax purposes notwithstanding any program of revaluation.

How to Appeal: *Only the applicant or those persons who previously submitted written comments or information to the Planning Director are entitled to appeal this decision.* A party who signed a petition may not appeal unless such a party also submitted independent written comments or information. An appeal must be in writing and delivered, along with fees set by ordinance, to the Planning Department by 5:00 p.m., October 12, 2015. For information about how to appeal, contact the Planning Department at (425)587-3225. An appeal of this project decision would be heard by the Hearing Examiner.

COMMENT TO CITY COUNCIL: If you do not file an appeal, but would like to express concerns about policies or regulations used in making this decision or about the decision making process, you may submit comments to citycouncil@kirklandwa.gov. Expressing your concerns in this way will not affect the decision on this application, but will enable the City Council to consider changes to policies, regulations or procedures that could affect future applications.